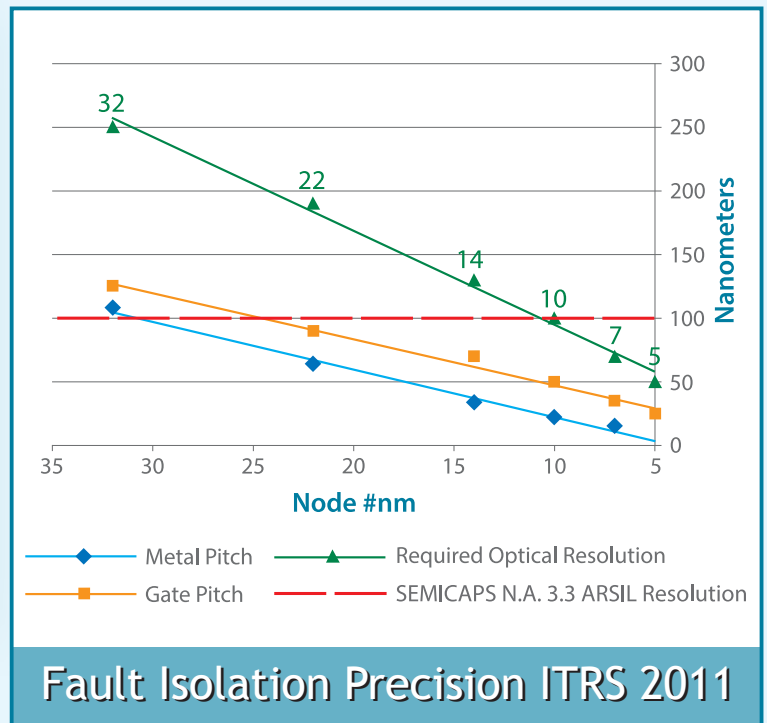
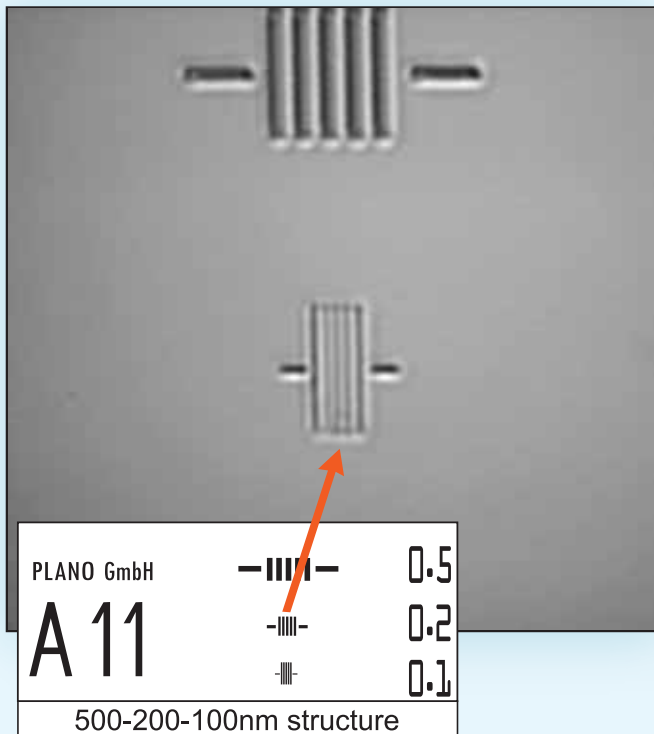


# SEMICAPS ARSIL

## World First N.A. 3.3 Aplanatic RSIL



Line-width resolution < 100 nm  
14 nm technology node qualified



- SEMICAPS Aplanatic RSIL - being used by a leading manufacturer for the 14 nm technology node
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- RSIL for imaging silicon wafer with a full backside thickness of up to 800  $\mu\text{m}$
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- Click and move feature

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